

Electronic Patent Application Fee Transmittal

Application Number:	10518371			
Filing Date:	28-Dec-2004			
Title of Invention:	Plasma chemical vapor deposition method and plasma chemical vapor deposition device			
First Named Inventor/Applicant Name:	Hiroshi Mashima			
Filer:	Marvin Jay Spivak/Isiah Avila			
Attorney Docket Number:	263787US2PCT			
Filed as Large Entity				
U.S. National Stage under 35 USC 371 Filing Fees				
Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Basic Filing:				
Pages:				
Claims:				
Miscellaneous-Filing:				
Petition:				
Patent-Appeals-and-Interference:				
Post-Allowance-and-Post-Issuance:				
Extension-of-Time:				
Extension - 2 months with \$0 paid	1252	1	490	490

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Miscellaneous:				
Request for continued examination	1801	1	810	810
Total in USD (\$)				1300